

**Figure 8.15** Calculated values of reflectance, Si absorbance, and metal absorbance for two cells, 5  $\mu$ m and 15  $\mu$ m thick, showing mechanisms of the enhanced absorption. The cells have front-polished and back-textured configuration. Texture height was 1.0  $\mu$ m

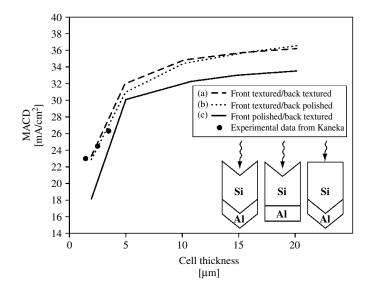


Figure 8.16 Calculated maximum photocurrent generated in a cell with light-trapping involving a metal reflector

the film thickness has reached about 10  $\mu$ m. Furthermore, texturing at both interfaces appears to be the most suitable cell configuration. Figure 8.16 includes experimental data from Kaneka [45, 46]; the solid points show excellent agreement with calculated results. One can deduce the effect of light-trapping by comparing  $J_{SC}$  values in Figures 8.1 and 8.3 for the same thickness of the cell. In Figure 8.1, the thickness required to generate a  $J_{SC}$  of 34 mA/cm<sup>2</sup> is 80  $\mu$ m. However, the structures of Figure 8.16 can produce the same values of  $J_{SC}$  for a thickness of about 10  $\mu$ m – a factor of 8 thinner.